

**In the Claims**

Claim 1 (currently amended): An RFID device comprising  
a substrate;  
an antenna means on said substrate, said antenna means ~~being comprised of~~ comprising a  
sintered metal toner ~~printed~~ formed in a pattern on said substrate comprising at least one  
loop;  
at least one silicon chip; and  
a connection means for electrically connecting said antenna means and said silicon chip.

Claim 2 (currently amended): The RFID device of claim 1 wherein said connection means  
comprises ~~is comprised of~~ an electrically conductive adhesive.

Claim 3 (currently amended): The RFID device of claim 1 wherein said connection means  
comprises ~~is comprised of~~:

a first coil means connected to said antenna means and  
a second coil means connected to said silicon chip[[]]  
wherein said first coil means and said second coil means are proximally located thereby  
facilitating electrical communication.

Claim 4 (currently amended): The RFID device of claim 3 wherein said first coil means comprises  
~~is comprised of~~ at least two loops wherein each of said at least two loops is separated by a layer of  
dielectric.

Claim 5 (original): The RFID device of claim 4 wherein said first coil means has at least a first and a second loop each loop having two endpoints,

wherein a first loop is located on said substrate and

a second loop is located on a dielectric layer located above said first loop,

wherein one endpoint of said first loop is connected to said antenna means and the second endpoint of said first loop is connected to the first endpoint of said second loop through a hole in the dielectric layer and

wherein the second endpoint of said second loop is connected to said antenna means through an opening in the dielectric layer.

Claim 6 (canceled)

Claim 7 (original): The RFID device of claim 3 wherein said second coil means is located on said silicon chip.

Claim 8 (currently amended): The RFID device of claim 1 wherein said antenna means is ~~printed on~~ applied to said substrate as a liquid toner before sintering.

Claim 9 (currently amended): The RFID device of claim 8 wherein ~~printing is by~~ application of said liquid toner is performed using electrostatic or inkjet printing methods.

Claim 10 (currently amended): The RFID device of claim 3 wherein said connection means is ~~printed by~~ applied to said RFID device using electrostatic or inkjet printing methods.

Claim 11 (currently amended): The RFID device of claim 7 wherein said second coil means is ~~printed by~~ applied to said RFID device using electrostatic or inkjet printing methods.

Claim 12 (original): The RFID device of claim 1 further comprising a protective coating.

Claim 13 (withdrawn): A process for the manufacture of RFID devices consisting of the following:

- a. Electrostatic printing of a metal toner on a coated substrate, said printing comprising an antenna having at least one loop;
- b. The drying of this metal toner image;
- c. The mechanical placement of a silicon die on this dried, printed metal toner image;
- d. The heating of this assembly to a suitable temperature causing a sintering of the metal toner particles together and a sintering of them to the electrode pads of the silicon die; and
- e. The overcoat of the die/substrate with a protective coat.

Claim 14 (withdrawn): The process of claim 13 in which the metal toner is made of silver.

Claim 15 (withdrawn): The process of claim 13 in which the substrate is PET film or paper.

Claim 16 (withdrawn): The process of claim 13 in which the substrate is coated with an adhesion/sintering layer that promotes both sintering of the metal particles and their adhesion to the substrates.

Claim 17 (withdrawn): The process of claim 16 in which this coating is chosen from Saran <sup>TM</sup> resins of Dow Chemical.

Claim 18 (withdrawn): A process for the manufacture of rf-ID devices in which:

- a. metal toner is printed on a suitable substrate in a suitable pattern;
- b. the pattern in the area of silicon chip mounting is configured into a single or multi-turn electro-magnetic coil;
- c. this pattern is suitably processed into a conductive metal pattern;
- d. the substrate is coated with a suitable adhesive layer;
- e. a silicon die possessing an electromagnetic coil pattern of metal around its periphery is placed and aligned to the metal toner coil pattern of the substrate; and
- f. the bonding reaction between die and adhesive coated substrate is completed by suitable means.

Claim 19 (withdrawn): The process of claim 18 in which the die has been “thinned” to a value below 50 microns.

Claim 20 (withdrawn): The process of claim 18 where the substrate thickness is less than 50 microns.

Claim 21 (withdrawn): The process of claim 18 where the overall thickness of the final part is between 10 and 100 microns.